

# United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS P.O. Box 1450 Alexandria, Vignita 22313-1450 www.nspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/003,179	10/31/2001	Tadaharu Watanabe	MTG009	4094
75	90 06/03/2003			
Steven C. Petersen Hogan & Hartson, LLP			EXAMINER	
Suite 1500 1200 17th Street			MEDINA SANABRIA, MARIBEL	
Denver, CO 80			ART UNIT	PAPER NUMBER
			1754	
			DATE MAILED: 06/03/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

S. Patent and Trad TO-326 (Rev.	04.04	on Summary		
2) U Notice	of References Cited (PTO-892) of Draftsperson's Patent Drawing Review (PTO-948) ation Disclosure Statement(s) (PTO-1449) Paper No(s) <u>5</u> .	5) 📙	Interview Summary (PTO-413) Paper No(s). Notice of Informal Patent Application (PTO-1 Other:	· 52)
Attachment(s				
15)∟J A	cknowledgment is made of a claim for domestic	priority under 3	5 U.S.C. §§ 120 and/or 121.	
	☐ The translation of the foreign language prov			plication).
	cknowledgment is made of a claim for domestic			onligati
* 51	application from the International Bure se the attached detailed Office action for a list o	eau (PCT Rule 1	7 2(a))	aye
;	3. Copies of the certified copies of the priori	tv documents ha	ve been received in this National St	200
	2. Certified copies of the priority documents			
	1.☐ Certified copies of the priority documents	have been reco	havi	
	All b) Some * c) None of:	priority under 30	o.o.o. g 113(a)-(u) of (I).	
	Acknowledgment is made of a claim for foreign	priority under 25	USC 8 110(a) (d) as (5)	
	nder 35 U.S.C. §§ 119 and 120			
12)∐ Т	The oath or declaration is objected to by the Exa		IOH.	
ا بــار	If approved, corrected drawings are required in rep			
11)□ ד	Applicant may not request that any objection to the he proposed drawing correction filed on	arawing(s) be hel	d in abeyance. See 37 CFR 1.85(a).	
1U)[_] I	The drawing(s) filed on is/are: a) accep			
	The specification is objected to by the Examiner			
	on Papers			
8) [(8	Claim(s) are subject to restriction and/or	election require	ment.	
	Claim(s) <u>26,28,29,31 and 38-40</u> is/are objected			
_	Claim(s) <u>1-25,27,30,32-37 and 41-66</u> is/are rejo			
5)	Claim(s) is/are allowed.			
	4a) Of the above claim(s) is/are withdraw	vn from consider	ation.	
4)🖂	Claim(s) 1-66 is/are pending in the application	ı <b>.</b>		
Dispositi	closed in accordance with the practice under to of Claims	Ex parte Quayle,	1935 C.D. 11, 453 O.G. 213.	
3)□	Since this application is in condition for allowa	ance except for fo	ormal matters, prosecution as to the	merits is
2a) <u></u> ☐	This action is <b>FINAL</b> . 2b)⊠ Th	is action is non-f	inal.	
1)⊠	Responsive to communication(s) filed on 31 (	October 2001 .		
I HE   - External formation of the control of the c	MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1.1. SIX (6) MONTHS from the mailing date of this communication. Period for reply specified above is less than thirty (30) days, a reply operiod for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, how y within the statutory mi will apply and will expire	ever, may a reply be timely filed  nimum of thirty (30) days will be considered timely.  SIX (6) MONTHS from the mailing date of this con	nmunication.
A SH	ORTENED STATUTORY PERIOD FOR REPLY	Y IS SET TO EX	PIRE 3 MONTH(S) FROM	
Period fo	The MAILING DATE of this communication apport Reply	pears on the cove	r sheet with the correspondence add	ress
	The State Dio Battle Co.	Maribel Medina	1	
	Office Action Summary	Examiner	Art Unit	
		10/003,179	WATANABE ET AL	_ /
		Application No	. Applicant(s)	<del>- #)</del>

Art Unit: 1754

#### **DETAILED ACTION**

#### Oath/Declaration

1. The oath or declaration is defective. A new oath or declaration in compliance with 37 CFR 1.67(a) identifying this application by application number and filing date is required. See MPEP §§ 602.01 and 602.02.

The oath or declaration is defective because: It does not identify the citizenship of each inventor. (Additional inventor Dan Fraenkel)

#### Claim Objections

- 2. Claims 49 and 66 are objected to because of the following informalities:
  - a. In claim 49, first line after "wherein", --the-- should be inserted.
  - b. In claim 66, fourth line, after "form" (first occurrence), --of-- should be inserted.

    Appropriate correction is required.

### Claim Rejections - 35 USC § 112

- 3. The following is a quotation of the second paragraph of 35 U.S.C. 112:
  - The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 4. Claims 10, 13, 47-65 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.
  - a. Claim 10 is indefinite for use of improper Markush language. The phrase that reads "selected from the group consisting of an oxide, a salt, an acid, an organic complex, or an inorganic complex of said metal" is confusing and renders the claim

Application/Control Number: 10/003,179

Art Unit: 1754

Page 3

indefinite. The phrase should be changed to --selected from the group consisting of an oxide, a salt, an acid, an organic complex, [or] and an inorganic complex of said metal--.

- b. Claim 13, recites the limitation "said precursor is heated under a flow of hydrogen" this limitation render the claim indefinite, since claim 9, recites that the precursor is heated under a flow of nitrogen. There is no antecedent in claim 9 for the use of hydrogen in claim 13.
- c. Claim 47 recites the limitation "said metal". There is insufficient antecedent basis for this limitation in the claim. The limitation should be changed to -[said] <u>a</u> metal--.
- d. Claim 55 recites the limitation "said metal". There is insufficient antecedent basis for this limitation in the claim. The limitation should be changed to -[said] a metal--.
- e. Claim 61 recites the limitation "said metal". There is insufficient antecedent basis for this limitation in the claim. The limitation should be changed to -[said] a metal--.
- f. Claim 65 recites the limitation "said metal". There is insufficient antecedent basis for this limitation in the claim. The limitation should be changed to -[said] a metal--.

## Claim Rejections - 35 USC § 102 and Claim Rejections - 35 USC § 103

5. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 6. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person

Art Unit: 1754

having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

7. Claims 1-6, 14-24, and 47-65 are rejected under 35 U.S.C. 102(b) as being anticipated by US Patent No. 4,976,944 (Pacaud et al).

In regards to claims 1 and 47, Pacaud et al disclose a method for the removal of impurities from a silane-containing gaseous stream. The method comprises contacting the gaseous stream with a purifier material to reduce the level of contaminants to less than 10 ppb (See col. 1, lines 10-23). The purifier material comprises a support having metallic copper deposited thereon (See col. 2, lines 30-32 and lines 52-54).

In regards to the limitation of claims 2, 19, 21, 50, 57, 61, and 65 that reads "wherein the oxidation state of said metal of said purifier thin layer is lower than the maximum oxidation state of said metal" Pacaud et al disclose that the copper is metallic copper (See col. 2, line 54), metallic copper is the zero oxidation state of copper, therefore this is an oxidation state lower than the maximum oxidation of copper.

In regards to the limitation of claims 3, 20, 22, 51, 58, and 62 that reads "wherein said thin layer of said purifier material further contains said metal in a zero oxidation state" Pacaud et al disclose that the copper is metallic copper (See col. 2, line 54), metallic copper is the zero oxidation state of copper.

In regards to claims 4, 52, 59 and 65 Pacaud et al disclose that the metal is copper (See col. 2, lines 30-33).

In regards to claims 5, 53, and 60, Pacaud et al disclose that the support may be any of silicoaluminates, titania, zirconia, alumina, silica and the like (See col. 2, lines 44-46).

Art Unit: 1754

In regards to claim 6, Pacaud et al disclose the removal of contaminants form silane containing gaseous streams.

In regards to claim 16, Pacaud et al disclose in col. 2, lines 52-54 a cooper concentration in the range from 3-15 % by weight.

In regards to the limitation of claims 14, 15, 17, 18, 23, 24, 48, 49, 55, 56, 63, 64, and 65, Pacaud et al disclose a surface area in the rang of 30 to  $600 \text{ m}^2/\text{g}$ .

In regards to claim 54, Pacaud et al disclose in col. 3, lines 23-26 that the material can be regenerated.

No difference is seen between the instantly claimed invention and Pacaud et al.

8. Claims 41-46 are rejected under 35 U.S.C. 102(b) as anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over US Patent No. 4,976,944 (Pacaud et al).

Pacaud et al disclose a purifier material comprising a support having metallic copper deposited thereon (See col. 2, lines 30-32 and lines 52-54).

In regards to claim 44 Pacaud et al disclose that the copper is metallic copper (See col. 2, line 54), metallic copper is the zero oxidation state of copper, therefore this is an oxidation state lower than the maximum one.

In regards to claim 46, Pacaud et al disclose in col. 3, lines 23-26 that the material can be regenerated.

In the event any differences can be shown for the product of the product by process claims 41-46, as opposed to the product taught by Pacaud et al, such differences would have been obvious to one of ordinary skill in the art as a routine modification of the product in the

Art Unit: 1754

absence of a showing of unexpected results; see also *In re Thorpe*, 227 USPQ 964 (Fed. Cir. 1985).

9. Claims 1-3, 5, 8-13, 21, 22, 25, 27, 30, 32, 33, 35, 36, 37, 41, 44, 45, 46, 47, 50, 51, 53, 54, 61, 62, and 66 are rejected under 35 U.S.C. 102(b) as being anticipated by US Patent No. 5,637,544 (Shadman).

In regards to claims 1, 21, 41, 47, and 61 Shadman discloses a method for removing contaminants from a silane or reactive gas stream comprising contacting the gas stream with a purifier material in order to reduce the levels of contaminants to parts per billion (See col. 1, lines 21-29). The purifier material comprises a substrate having deposited thereon one or more reduced forms of a metal oxide (See col. 2, lines 25-31).

In regards to the limitation of claims 2, 21, 32, 44, 50, 61, and 66 that reads "wherein the oxidation state of said metal of said purifier thin layer is lower than the maximum oxidation state of said metal" Shadman discloses that the term "reduced" as used in his invention "relates to the oxidation state of the metal in that the oxygen is present in less than the stoichiometric amount in the metal oxide (i.e., the metal species is partially or substantially deoxygenated)" (See col. 5, lines 3-15).

In regards to the limitation of claims 3, 22, 33, 45, 51, and 62 that reads "wherein said thin layer of said purifier material further contains said metal in a zero oxidation state" Shadman discloses "the metal species is partially or substantially deoxygenated" (See col. 5, lines 3-15), "substantially deoxygenated has been interpreted as being the zero oxidation state of the metal.

In regards to claims 5, 35, 53, and 60, Shadman discloses that the support may be any of Titania, zirconia, and alumina (See col. 4, lines 1-5).

Page 7

Application/Control Number: 10/003,179

Art Unit: 1754

In regards to claims 8 and 37 Shadman discloses that the contaminants removed are among others are oxygen and moisture (See col. 1, lines 21-27).

In regards to claims 9, 25 and 66, Shadman discloses a method for preparing a purifier material comprising the steps of: a) providing a precursor of metal deposited on a substrate, wherein the metal may be oxidized or deoxygenated (see col. 5, lines 20-23); b) heating the precursor under a flow of inert gas such as nitrogen at a temperature range up to 200°C (See col. 5, liens 62-67); c) treating the substrate from step b) with a reducing agent to thereby produce the purifier material (See col. 6, lines 1-35).

In regards to claim 10, Shadman discloses that precursor may be an oxide of the metal (See col. 5, lines 29-30).

In regards to claim 11, Shadman discloses the use of vapor deposition (See col. 5, lines 24-26).

In regards to claims 27, Shadman discloses the use of 2 to about 35 % by weight of hydrogen the rest being an inert gas (See col. 6, lines 27-33).

In regards to claims 46 and 54, Shadman discloses in col. 8, lines 37-49, that the purifier material may be regenerated.

No difference is seen between the instantly claimed invention and Shadman.

10. Claims 7 and 34 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shadman.

Shadman applies here in as above.

In regards to claim 7, Shadman fails to disclose or exemplified his invention that the reactive gas treated is one selected from the group consisting of trimethyl aluminum, trimethyl

Art Unit: 1754

gallium and trimethyl indium. Shadman discloses that this method may be used to treat reactive

gases generated in semiconductors process. It would have been obvious to one of ordinary skill

in the art at the time the invention was made to treat gases containing the above cited gases since

this are common gases in semiconductors processes. On e of ordinary skilled din the art would

have been motivated to treat any reactive gases generated in semiconductor process in order to

remove moisture and oxygen contaminants.

In regards to claim 34, Shadman fails to disclose the metals cited in claim 34. It would

have been obvious to one of ordinary skill in the art at the time the invention was made to have

used as the active meal any of the cited metals, since Shadman discloses in col. 5, lines 15-20

that any metal capable of reacting with trace impurities may be used.

Allowable Subject Matter

Claims 26, 28-29, 31 and 38-40 are objected to as being dependent upon a rejected base 11.

claim, but would be allowable if rewritten in independent form including all of the limitations of

the base claim and any intervening claims.

Conclusion

Any inquiry concerning this communication or earlier communications from the 12.

examiner should be directed to the examiner Maribel Medina. The examiner can normally be

reached on Monday through Friday from 7:30 AM to 3:30 PM. Any inquiry of a general nature

or relating to the status of this application or proceeding should be directed to the receptionist

whose telephone number is 703-308-0661.

Examiner: Maribel Medina MM

Tel: 703-305-1928

Fax: 703-872-9310 May 30, 2003

TECHNOLOGY CENTER 1700

Page 8